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## AMENDMENTS TO THE CLAIMS

Please amend the claims as follows:

1. (PREVIOUSLY PRESENTED) A portion of a mold apparatus for manufacturing a light guide, comprising:

a stamper configured to define a surface of a light guide; and

a core material portion fixed to said stamper by a fixing structure, wherein said fixing structure comprises at least one fastening member,

wherein said at least one fastening member extends through said core material portion into said stamper.

## 2. (CANCELED)

- 3. (ORIGINAL) The portion of a mold apparatus according to claim 1, wherein said at least one fastening member is at least one bolt.
- 4. (PREVIOUSLY PRESENTED) The portion of a mold apparatus according to claim 1, wherein said stamper is between 6 and 12 mm thick.

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5. (PREVIOUSLY PRESENTED) A method of manufacturing a light

guide, comprising:

defining a molding chamber, including defining at least one surface of

the molding chamber with a stamper configured to define a surface of a light

guide, wherein the stamper is a stamper electrotype fixedly mounted on a core

material portion using at least one fastening member;

molding a molding material in the molding chamber to form a light guide

having a surface thereof defined by the stamper; and

forming at least one fastener hole through the core material portion and

extending into the stamper electrotype.

6. (CANCELED)

7. (ORIGINAL) The method according to claim 5, wherein the at least

one fastening member is a bolt.

8. (ORIGINAL) The method according to claim 7, wherein the stamper

electrotype is between 6 and 12 mm thick.

9. (PREVIOUSLY PRESENTED) The portion of a mold apparatus

according to claim 1, wherein the stamper is a stamper electrotype.

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10. (PREVIOUSLY PRESENTED) The portion of a mold apparatus

according to claim 9, wherein the stamper electrotype is formed from nickel.

11. (PREVIOUSLY PRESENTED) The method according to claim 5,

wherein the stamper electrotype is formed from nickel.

12. (PREVIOUSLY PRESENTED) The portion of a mold apparatus

according to claim 1, wherein the stamper and the core material portion form

an integral molding device.

13. (PREVIOUSLY PRESENTED) The portion of a mold apparatus

according to claim 12, wherein the mold apparatus further comprises a

movable core and a movable molding plate that holds the movable core and the

integral molding device.

14. (PREVIOUSLY PRESENTED) The method according to claim 5,

wherein the stamper and the core material portion form an integral molding

device.

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15. (PREVIOUSLY PRESENTED) The method according to claim 14,

wherein the integral molding device is set in a movable core and a movable

molding plate that holds the movable core and the integral molding device.

16. (PREVIOUSLY PRESENTED) The portion of a mold apparatus

according to claim 1, wherein the stamper and the core material portion are

both formed from nickel.

17. (PREVIOUSLY PRESENTED) The method according to claim 5,

further comprising forming both the stamper and the core material portion

from nickel.

18. (PREVIOUSLY PRESENTED) The portion of a mold apparatus

according to claim 1, wherein the stamper and the core material portion

together form a movable core of the mold apparatus.

19. (PREVIOUSLY PRESENTED) The method according to claim 5,

wherein the stamper and the core material portion together form a movable

core of a mold apparatus.

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20. (NEW) The portion of a mold apparatus according to claim 1,

wherein a plurality of evenly spaced grooves are formed on a part of a surface

of the stamper and a plurality of unevenness grooves are formed on another

part of the surface of the stamper.

21. (NEW) The portion of a mold apparatus according to claim 20,

wherein the plurality of unevenness grooves are prism shaped.

22. (NEW) The portion of a mold apparatus according to claim 20,

wherein a pitch width of the plurality of unevenness grooves substantially

ranges between 0.07 mm to 0.08 mm.

23. (NEW) The portion of a mold apparatus according to claim 1,

wherein the stamper is configured such that the surface of the light

guide defined by the stamper is a surface of the light guide opposite a light

emitting surface of the light guide, and

wherein the light emitting surface is the surface from which the light

from the light guide is emitted toward a display panel.

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24. (NEW) The portion of a mold apparatus according to claim 1,

wherein a thickness of the core material portion substantially ranges between

20 mm and 30 mm.

25. (NEW) The method according to claim 5, further comprising:

forming a plurality of evenly spaced grooves on a part of a surface of the

stamper that defines the surface of the light guide; and

forming a plurality of unevenness grooves on another part of the surface

of the stamper.

26. (NEW) The method according to claim 25, wherein the step of

forming the plurality of unevenness grooves includes:

forming the plurality of unevenness grooves such that they are prism

shaped.

27. (NEW) The method according to claim 25, wherein the step of

forming the plurality of unevenness grooves includes:

forming the plurality of unevenness grooves such that a pitch width of

the plurality of unevenness grooves substantially ranges between 0.07 mm to

0.08 mm.

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28. (NEW) The method according to claim 5, wherein the step defining

the surface of the light guide comprises:

defining such that the surface of the light guide defined by the stamper is

a surface of the light guide opposite a light emitting surface of the light guide,

wherein the light emitting surface is the surface from which the light

from the light guide is emitted toward a display panel.

29. (NEW) The method according to claim 5, wherein the step of

defining the molding chamber includes using the core material portion whose

thickness substantially ranges between 20 mm and 30 mm.